



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of : Confirmation No. 9938
Hiroshi TAKANASHI et al. : Docket No. 2001_0476
Serial No. 09/838,118 : Group Art Unit 1752
Filed April 20, 2001 : Examiner S. Lee

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SEP 25 2003
TC 1700

NEGATIVE-WORKING PHOTOSENSITIVE
RESIN COMPOSITION AND PHOTOSENSITIVE
RESIN PLATE USING THE SAME

PETITION FOR EXTENSION OF TIME

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Petition hereby is made for a three month extension of time to respond to the communication of
March 20, 2003.

The fee of \$930.00 is

☒ (X) submitted herewith.

☐ () to be charged to Deposit Account No. 23-0975. A duplicate copy of this Petition is
enclosed.

☐ () Small entity status of this application is established by a Small Entity Status Assertion
which

☐ () is enclosed.

☐ () has been previously submitted.

Respectfully submitted,

Hiroshi TAKANASHI et al.

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September 22, 2003